Personal Data Processing Agreement

This agreement ("Agreement") outlines how National Chung Hsing University ("Party A") handles the personal data collected from the attached form.

By checking the box indicating their consent, the applicant ("Party B") acknowledges that they have read, understood, and accepted the terms set forth herein and any future amendments made thereto. If Party B is under the age of 20, Party B shall ask their legal representative to sign this Agreement to show that they have read, understood, and accepted the terms set forth herein and any future amendments made thereto before Party B may begin using this service. However, if Party B has already signed this Agreement, Party A shall deem Party B's legal representative to have provided their consent and agreement to be bound by the following terms:

I. Collection, revision, and maintenance of personal data

- 1. Party A shall collect, process, and use Party B's personal data in accordance with Party A's *Privacy Policy* and the *Personal Data Protection Act* of the Republic of China.
- 2. Party B shall provide accurate, complete, and up-to-date personal data during the application process.
- 3. Party A needs to collect Party B's name, nationality, identification number, contact number, address, and email in order to process Party B's application.
- 4. Party B shall contact Party A to update their personal data in the event of any changes to ensure that the data on file is accurate, complete, and up to date.
- 5. Party B acknowledges that the provision of erroneous, false, outdated, incomplete, or misleading information may lead to the forfeiture of certain rights and interests.
- 6. Pursuant to the *Personal Data Protection Act* of the Republic of China, Party B may exercise the following rights regarding the personal data they have on file with Party A: (1) making a request to review their personal data; (2) requesting a copy of their personal data; (3) supplementing or making corrections to their personal data; (4) requesting the cessation of the collection, processing, and use of their personal data; (5) requesting the erasure of their personal data (Party A may decline data erasure requests if it must use the data for official purposes).

To exercise the aforementioned rights, Party B shall submit a request to the contact person indicated in Party A's *Privacy Policy*. Party B acknowledges that Party A disclaims any and all liability for damage resulting from Party B's exercise of the aforementioned rights.

II. Purpose of personal data collection

- 1. Party A requires Party B's personal data in order to process Party B's patent application.
- 2. Party A must obtain Party B's consent in writing before Party A may use Party B's personal data for a purpose not indicated above. Party B may object to such requests but may lose certain rights and interests as a result of their objection.
- 3. Party A may use Party B's personal data for a period of up to 30 years in Taiwan, beginning from the date of signing (the actual data usage period may be adjusted for each form based on actual conditions).

III. Confidentiality

Party B's personal data will be protected in accordance with Party A's *Privacy Policy*. In the event that Party B's personal data is stolen, leaked, tampered with, or otherwise infringed upon due to Party A's violation of the *Personal Data Protection Act* or due to a natural disaster, accident, or other force majeure event, Party A shall conduct an investigation and notify Party B of the results through telephone, mail, email, website announcement, or other appropriate means.

IV. Validity

- 1. Party B acknowledges that their signature signifies that they have read, understood, and agreed to the terms and conditions stipulated herein, and that Party A may terminate all services and rights provided to Party B at any time if the latter violates any of the terms and conditions stipulated herein.
- 2. Party A reserves the right to modify the contents of this Agreement at any time via an announcement on its website (webpage) without notice to Party B, who shall stop using the services provided by Party A if they do not accept the modified terms. Party B's continued use of such services shall constitute their agreement to the modified terms.
- 3. Any advice or information provided to Party B regarding this Agreement, whether verbally or in writing, does not constitute the terms of this Agreement unless expressly stipulated herein.

V. Jurisdiction

The interpretation and applicability of this Agreement and any disputes arising therefrom shall be subject to the law of the Republic of China. Both parties agree to designate the Taiwan Taichung District Court as the court of first instance.

By checking the box to the left, Party B certifies that they have read and accepted the terms above. Party B's signature: ______ (Please sign personally.)

Date: ____/___/____(MM/DD/YYYY)

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^{*} NCHU_IPForm1-1 NCHU Faculty and Research Fellow R&D Outcomes Patent Application (effective Aug. 01, 2014)

NCHU Faculty and Research Fellow R&D Outcomes: Invention / Utility Model / Design Patent Application

Date of application: ____/___ (MM/DD/YYYY) Chinese 1. Patent English Contact Phone: Name 2. R&D info Email: Representative Unit Job title Name: 3. Contact Phone: Email: person □ NCHU 4. Attribution □ Shared (Please fill in the organization with which the rights will be shared and the of the R&D percentages assigned to NCHU and the organization.) outcomes NCHU [%], shared with _____ (organization name) [_____%] **Note:** Please attach the contract to this application. 5. Source of \square NSTC \square MOA \square MoEA \square Other: □ Academia-industry collaboration R&D outcomes □ R&D outcomes developed by faculty members in the course of their work (skip the (The principal following fields) investigator must be the NCHU control number: Project number: representative Project name: if applicable) □ Republic of China □ Foreign country/countries: ____ 6. Jurisdiction (Please list countries in order of priority) (and reason if Reason(s) for application: application is Notes: submitted in a 1. For applications paid for by the applicant or a third party, the cost-sharing structure for foreign domestic and foreign applications shall be the same. 2. If the applicant wishes to file a patent in mainland China, the application must be filed on country) the same day on which the patent is first filed in another country. Failure to do so will result in the forfeiture of "domestic priority" in mainland China. Have the target R&D outcomes been publicly released? \Box Yes \Box No, but they will be in the future. \Box No, there is no plan to release the R&D outcomes (skip the following field). Purpose, method, and date of initial (or planned) release: □ Degree thesis/dissertation: Oral defense date _____; submission date _____ 7. Records of □ Domestic/international journal: ; (expected) publication date_____ public release Submission date___ □ Public presentation: Date ____ _____ (e.g., poster, presentation, report) Format: □ Final project report: _____ \Box Other: Note: Please include the published journal article, thesis, or dissertation (Chinese translation required for those written in a foreign language).

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* NCHU_IPForm1-1 NCHU Faculty and Research Fellow R&D Outcomes: Invention/Utility Model/Design Patent Application (effective Oct. 2022)

8. Application documents	 Invention patent application [Form 1] Invention patent revenue distribution agreement [Form 2] Invention patent information sheet [Form 3] Approved budget list (for government-commissioned projects) or project contract (for academia-industry collaboration projects) Please email the above documents to tlo@nchu.edu.tw. Supplementary documents:
9. Agency	 Agency selected by the Academia-Industry Collaboration Center Note: Applications partially paid for by the University must be handled by an agency selected by the Academia-Industry Collaboration Center. Agency recommended by the inventor:

• Certification by the R&D representative:

- 1. I hereby certify that the R&D outcomes associated with this patent application (including the information provided in Forms 1/2/3) was fully and completely developed by me personally or by my team under the auspices of National Chung Hsing University as part of my research duties, and I agree to bear all legal liability for any infringement of others' rights arising from any misrepresentation herein.
- 2. I certify that all R&D personnel have agreed to the following stipulations:
 - (1) The patent will be registered under the name of National Chung Hsing University.
 - (2) In principle, approved patents will be maintained by the University for a period of at least five years.
- 3. I agree to bear all costs of a rejected application if the R&D outcomes do not satisfy the novelty requirement due to any misrepresentation under Item 7 ("Records of public release") herein that can be attributed to the R&D personnel or related project personnel.
- 4. I hereby declare that all of the information provided above is true and correct to the best of my knowledge and that I agree to be bound by the above terms and conditions.

Signature of representative:		Date of signing:			
	Unit/Personnel	Percentage (\checkmark)		Signature of approval	
Cost- sharing structure	R&D personnel	□ 100%	□ 40%		
	Department/ Institute	□ 8%	□ 0%		
	College	□ 2%	□ 0%		
		□ 50%	□ 52%	AICC	President
	University	□ 58%	□ 60%		
		$\Box 0\%$			

Notes:

- 1. For patent rights shared with third parties, the percentage of <u>costs borne by such third parties shall be</u> <u>deducted</u> from the calculation in the table above.
- 2. Article 5, Paragraph 1, Subparagraph 7 of the NCHU Regulations for the Management and Utilization of Research and Development Outcomes: "R&D personnel who fail to pay for [their share of] the costs and still refuse to do so within 30 days of receiving a payment notice from the Division shall be barred from applying for intellectual property rights registration for a period of three years. Furthermore, the University will suspend any ongoing applications for or maintenance of already registered intellectual property rights associated with said personnel."

3. Article 8, Paragraph 2 of the same *Regulations*: "If the ... college and department (graduate institute) choose not to or are otherwise not required to share costs, the corresponding percentages shall be included in the University Endowment Fund."

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^{*} NCHU_IPForm1-1 NCHU Faculty and Research Fellow R&D Outcomes: Invention/Utility Model/Design Patent Application (effective Oct. 2022)

NCHU Faculty and Research Fellow R&D Outcomes:

Contribution Percentage and Revenue Distribution Agreement

(For patent rights belonging to the University)

I. Patent title: _________ (to be filled in by the Patent and Technology Transfer Division)

- III. The cost-and-revenue sharing structure for the patent shall be subject to the National Chung Hsing University ("the University") *Regulations for the Management and Utilization of Research and Development Outcomes* and the terms and conditions stipulated herein.
 - 1. **Revenue distribution** scheme:
 - 1. For patent applications **partially paid for by the University**: After deducting royalties payable to the commissioning agency, the remaining revenue shall be shared between the **University and the inventors in a 60–40 ratio**.
 - For patent applications paid for by the inventors or a third-party company: After deducting the royalties payable to the commissioning agency, the remaining royalty revenue shall be shared between the University and the inventors in a 20–80 ratio.
 - Note 1: Royalties for R&D outcomes derived from a **government-commissioned** project shall be withheld in accordance with the terms stipulated by the commissioning agency, with the remaining portions of the royalty revenue distributed in accordance with the ratios set forth above.
 - Note 2: The revenue distribution ratios for colleges, departments, and graduate institutes shall be subject to the University's *Regulations for the Management and Utilization of Research and Development Outcomes*.
 - 2. If the R&D team consists of two or more researchers, they shall negotiate among themselves to determine the revenue-sharing structure and indicate the revenue distribution ratios in the table below. Future revenue distribution will be handled in accordance with the table.

No.	R&D personnel	Contribution	Revenue distribution	Remarks
1	(Representative)	%	%	
2		%	%	
3		%	%	
	Total	100%	100%	If the R&D team includes non-NCHU personnel, please also fill out the Patent Rights Waiver for Non-NCHU Inventors.

Note 1: Revenue distribution ratios may be adjusted based on the actual conditions of the technology transfer project with the consent of all R&D personnel involved.

- Note 2: Pursuant to the University's *Regulations for the Management and Utilization of Research and Development Outcomes*, the costs associated with patent application and maintenance shall be borne by the representative.
- IV. Signatures of all R&D personnel in acknowledgement of the cost-and-revenue sharing structure indicated above:

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^{*} NCHU_IPForm1-1 NCHU Faculty and Research Fellow R&D Outcomes: Invention/Utility Model/Design Patent Application (effective Oct. 2022)

1. R&D personnel:	(signature/seal)
2 R&D personnel:	(signature/seal)

2. KaD personner.	(signature/sear)
3. R&D personnel:	(signature/seal)

Date: _	//	(MM/DD/YYYY)
Date:	//	(MM/DD/YYYY)
Date:	/	(MM/DD/YYYY)

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^{*} NCHU_IPForm1-1 NCHU Faculty and Research Fellow R&D Outcomes: Invention/Utility Model/Design Patent Application (effective Oct. 2022)

NCHU Faculty and Research Fellow R&D Outcomes. Patent Application Information Sheet

1. Personal information of R&D personnel (affix additional tables if necessary)

		No	of
Chinese name	English name		
National identification number	Nationality		
Affiliation	Job title		
Tel	Fax		
Email			
Household registration address			
Mailing address			

[Note] Students with a full-time job and in-service master's program students must obtain written consent from their employer in order to be listed as an inventor.

		No	10
Chinese name	English name		
National identification number	Nationality		
Affiliation	Job title		
Tel	Fax		
Email			
Household registration address			
Mailing address			

[Note] Students with a full-time job and in-service master's program students must obtain written consent from their employer in order to be listed as an inventor.

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^{*} NCHU_IPForm1-1 NCHU Faculty and Research Fellow R&D Outcomes: Invention/Utility Model/Design Patent Application (effective Oct. 2022)

2. Patent information

1) Earliest		
record of the		
invention		
	1. Keyword ar	nd database search history:
	♦ Kevwo	rds used:
	Chin	lese:
2	Engl	ish:
2)	♦ Databa	ses searched
Prior research in	v Duluou	
similar		
technologies	2. Published li	terature or existing similar technologies:
		□ Mechanical engineering □ Civil engineering
	.	□ Hydraulic engineering □ Materials engineering
3) Discipline	Engineering	\Box Environmental engineering \Box Medical engineering
	technology	□ Nano technology □ Microfluidic chips □ Other:
	-	\Box Genetic engineering \Box Biomedical testing \Box Biomedicine
(Select the category	Biotech	□ Biochips □ Microbiology □ Animal vaccines □ IT chips
first and then select		□ Protein engineering □ Dietary supplements □ Other:
all itoms under that	- IT and	\Box IT \Box Telecommunications \Box Computer electronics \Box
an items under that	Automation	Microelectronic engineering Network technologies Photonics
category that	Automation	\Box Electrical engineering \Box Automation \Box Other:
apply.	Material	Pharmaceutical chemistry Materials chemistry
	and	\Box Ontoelectronic materials \Box Cosmetic chemistry
	chemical	\square Analytical chemistry \square Biomedical chemistry \square Other:
(Decuired)	engineering	
(Kequireu)		\Box Information management systems \Box Industry management
	Management	I elecommunications management Description of the second
	- 0/1	Business management models \Box Other:
4) Purpose of the		
invention		
(Required)		
5)		
Abstract		
(Chinese)		
(Describe the		
properties and		
features of the		
invention in clear,		
concise sentences.)		
(Required)		
6) Abstract		
(English)		

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7) Features of	1. Comparison to existing technologies
the invention	
(Please include at	
least one example	2 Features and characteristics
that best describes	
the features and	
characteristics of the	
technology.)	
(Required)	
8) Description of	
the invention or	
creation	
(Give an overview	
of existing	
technologies and	
then itemize the	
invention's	
technologies	
contents, features.	
and functions.	
Please also include	
drawings/diagrams	
to help technology	
users understand it	
and its	
applicability.)	
(Required)	
9) Scope of the	
patent application	
(I.e., patent claims.	
Before defining the	
scope, please briefly	
connections between	
this invention or	
creation with the	
original research	
project, including on	
which page(s) this	
invention or creation	
appears in the final	
project report.)	
(Required)	
10) D	
10) Drawings/	
Diagrams	
(Domirod)	
(Nequireu)	

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3. Promotion

	 TRL1 (Basic principles observed) TRL2 (Technology concept formulated) TRL3 (Analytical and experimental critical components) TRL4 (Technology validated in lab) TRL5 (Technology validated in relevant environment) TRL6 (Technology demonstrated in relevant environment) TRL7 (System prototype demonstration in operational environment) TRL8 (System complete and qualified) TRL9 (Actual system proven in operational environment)
1) Technology readiness level (TRL) (Required)	 TRL 1 – Basic principles observed Scientific knowledge generated underpinning hardware technology concepts/applications. Scientific knowledge generated underpinning basic properties of software architecture and mathematical formulation. TRL 2 – Technology concept formulated Invention begins, practical application is identified but is speculative, no experimental proof or detailed analysis is available to support the conjecture. Practical application is identified but is speculative, no experimental proof or detailed analysis is available to support the conjecture. Practical application is identified but is speculative, no experimental proof or detailed analysis is available to support the conjecture. Basic properties of algorithms, representations and concepts defined. Basic principles coded. Experiments performed with synthetic data. TRL 3 – Analytical and experimental critical components Analytical studies place the technology in an appropriate context and laboratory demonstrations, modeling and simulation validate analytical prediction. Development of limited functionality to validate critical properties and predictions using non-integrated software components. TRL 4 – Technology validated in lab A low fidelity system/component breadboard is built and operated to demonstrate basic functionality and critical test environments, and associated performance predictions are defined relative to the final operating environment. Key, functionally critical, software components are integrated, and functionally validated in relevant environment A medium fidelity system/component brass board is built and operated to demonstrate overall performance in a simulated operational environment with realistic support elements that demonstrates overall performance in critical areas. Performance predictions are made for subsequent development phases. End-to-end software elements implemented and interfaced with existi

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	critical scaling issues is built and operated in a relevant environment to demonstrate operations under critical environmental conditions. Prototype implementations of the software demonstrated on full-scale realistic problems. Partially integrate with existing hardware/software systems. Limited documentation available. Engineering feasibility fully demonstrated. TRL 7 – System prototype demonstration in operational environment Prototype software exists having all key functionality available for demonstration and test. Well integrated with operational hardware/software systems demonstrating operational feasibility. TRL 8 – System complete and qualified The final product in its final configuration is successfully demonstrated through test and analysis for its intended operational environment and platform TRL 9 – Actual system proven in operational environment The final product is successfully commercialized and made available to the market
2) Industry	(Please list possible utility and applications for the technology in as detailed a way as
applications	possible.)
(Required)	
3) Methods of promotion	 Please select up to three methods of promotion based on current technology developments and future development plans: Patent license Technology transfer Academia–industry collaboration Spin-off company Consulting Technology presentation Publication Commissioned development Other:
4) Target industries (Required)	 Agriculture/forestry/fishery/animal husbandry Mining and quarrying Manufacturing Water/electricity/gas/utilities Construction/development Wholesale, retail, and dining/food & beverages Transportation, warehousing, and telecommunications Banking, finance, insurance, and real estate Professional, science, or technological services Cultural, fitness, recreational, and other service industries Other:

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5) Recommended requirements for recipient(s) of the technology	
6) Potential benefits of the technology (Describe the value that it creates.)	
7) Business(es) that can utilize the technology and its/there current state of operations (Confidential)	 Business that can utilize the invention: Contact person: Status of the business' products and technologies

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